

SYSTEM AND METHOD FOR READING A MEMORY CELL

Background of the Invention

[0001] Magnetic Random Access Memory ("MRAM") is a non-volatile memory that may be suitable for long term data storage. MRAM devices may perform read and write operations faster than conventional long term storage devices such as hard drives. In addition, MRAM devices may be more compact and may consume less power than conventional storage devices.

[0002] A typical MRAM device may include an array of memory cells where word lines extend along rows of the memory cells and bit lines extend along columns of the memory cells. Each memory cell may be located at a cross point of a word line and a bit line.

[0003] A memory cell in an MRAM device stores a bit of information according to an orientation of a magnetization. The magnetization of a memory cell assumes one of two stable orientations at a given time. These two orientations are known as parallel and anti-parallel and represent logic level values of '0' and '1', respectively.

[0004] The magnetization orientation affects the resistance of a memory cell such as a spin dependent tunneling junction device. For instance, the resistance of a memory cell is a first value R if the magnetization orientation is parallel, the resistance of the memory cell is increased to a second value $(R + \Delta R)$ if the magnetization orientation changed from parallel to anti-parallel. The magnetization orientation of a selected memory cell, and therefore the logic state of the memory cell, may be read by determining the resistance state of the selected memory cell.

[0005] One of the challenges with MRAM devices involves electrically isolating the circuits that comprise the memory cells while maintaining a sufficient level of packing density. Although additional components such as transistors may be used to increase the isolation of memory cells, an increase in the number of components typically results in a decrease in the packing density of the memory cells, i.e., the number of memory cells per a given area, and a decrease in the packing density generally results in increased costs. It would be desirable to be

able to increase packing densities while increasing the electrical isolation of memory cells and while improving the read performance of the MRAM memory.

Summary of the Invention

[0006] In one exemplary embodiment, the present disclosure provides a method of performing a read operation from a first memory cell in a memory cell string that includes the first memory cell coupled to a second memory cell. The method includes providing a voltage to a first end of the first memory cell string that is closest to the first memory cell, providing a ground source to a second end of the first memory cell string that is opposite the first end, and determining whether a voltage change occurred at a node between the first and second memory cells in response to writing the first memory cell to a first state.

Brief Description of the Drawings

[0007] Embodiments of the invention are better understood with reference to the following drawings. The elements of the drawings are not necessarily to scale relative to each other. Like reference numerals designate corresponding similar parts.

[0008] Figure 1 is a diagram illustrating an embodiment of a data storage device that includes memory cell strings.

[0009] Figure 2a is a diagram illustrating an embodiment of a parallel magnetization orientation of an MRAM memory cell.

[0010] Figure 2b is a diagram illustrating an embodiment of an anti-parallel magnetization orientation of an MRAM memory cell.

[0011] Figure 3 is a diagram illustrating an embodiment of a first system for reading a memory cell in a memory cell string.

[0012] Figure 4 is a flow chart illustrating an embodiment of a first method for reading a memory cell in memory cell string.

[0013] Figure 5 is a diagram illustrating an embodiment of a second system for reading a memory cell in a memory cell string.

[0014] Figure 6 is a flow chart illustrating an embodiment of a second method for reading a memory cell in memory cell string.

[0015] Figure 7 is a diagram illustrating an embodiment of an MRAM device that includes multiple levels.

[0016] Figure 8 is a diagram illustrating an embodiment of a system that includes one or more MRAM devices.

Detailed Description

[0017] As shown in the drawings for purposes of illustration, the present invention is embodied in an MRAM device. The MRAM device includes an array of memory cells and circuitry for reliably sensing resistance states of the memory cells. The array of memory cells is divided into memory cell strings as described herein. To read a memory cell in a memory cell string, the output of a voltage divider circuit is determined before and after the memory cell is written to a first state using a voltage. If the voltage divider output does not change after being written to the first state, then the memory cell was in the first state prior to being written to the first state. If the voltage divider output changes after being written to the first state, then the memory cell was in a second state prior to being written to the first state. In this case, the memory cell is written back to the second state.

[0018] Reference is now made to Figure 1, which illustrates an embodiment of an MRAM device 8 including an array 10 of memory cell strings 12. Each memory cell string includes a plurality of memory cells as shown in the embodiments of Figures 3 and 5. The memory cell strings 12 are arranged in rows and columns, with the rows extending along an x-direction and the columns extending along a y-direction. Only a relatively small number of memory cell strings 12 are shown to simplify the description of the invention. In practice, arrays of any size may be used with any number of memory cell strings. The memory cell strings may each include any number of memory cells greater than or equal to two.

[0019] Traces functioning as word lines 14 extend along the x-direction in a plane on one side of the memory cell array 10. The word lines 14 shown in

Figure 1 represent one word line for each memory cell in memory cell strings 12. Traces functioning as write and read bit lines 16w and 16r, respectively, extend along the y-direction in a plane on an opposite side of the memory cell array 10. Each memory cell in memory cell strings 12 is located at a cross point of a corresponding word line 14 and bit lines 16w and 16r.

[0020] The memory cells are not limited to any particular type of device. For example the memory cells may be spin dependent tunneling (“SDT”) junction devices.

[0021] Referring now to Figures 2a and 2b, a typical SDT junction device includes a pinned layer 52 having a magnetization that is oriented in a plane of the pinned layer 52 but fixed so as not to rotate in the presence of an applied magnetic field in a range of interest. The SDT junction device also includes a “free” layer 50 having a magnetization orientation that is not pinned. Rather, the magnetization can be oriented in either of two directions along an axis (the “easy” axis) lying in the plane of the free layer 50. If the magnetization of the free and pinned layers 50 and 52 are in the same direction, the orientation is said to be “parallel” (as indicated by the arrows in Figure 2a). If the magnetization of the free and pinned 50 and 52 layers are in opposite directions, the orientation is said to be “anti-parallel” (as indicated by the arrows in Figure 2b). The magnetization in the free layer 50 may be oriented by applying write currents to word and bit lines 14 and 16w that cross the memory cell.

[0022] The free and pinned layers 50 and 52 are separated by an insulating tunnel barrier 51. The insulating tunnel barrier 51 allows quantum mechanical tunneling to occur between the free and pinned layers 50 and 52. This tunneling phenomenon is electron spin dependent, making the resistance of the SDT junction device 12 a function of the relative orientations of the magnetization of the free and pinned layers 50 and 52. For instance, resistance of the SDT junction device is a first value R if the orientation of magnetization of the free and pinned layers 50 and 52 is parallel and a second value $(R+\Delta R)$ if the magnetization of orientation is anti-parallel.

[0023] Returning to Figure 1, the MRAM device 8 also includes a row decode circuit 18. During write operations, the row decode circuit 18 applies a write

current to a selected word line 14 to cause a memory cell to be written to a desired state. During read operations, the row decode circuit 18 applies a write current to a selected word line 14 to cause a memory cell to be written to a known state and may apply a write current to the selected word line 14 to cause the memory cell to be written to a previous state.

[0024] The MRAM device 8 further includes a column decode circuit 20. During write operations, the column decode circuit 20 applies a write current to selected bit lines 16w. During read operations, column decode circuit 20 applies a write current to a selected bit line 16w to cause a memory cell to be written to a known state and may apply a write current to the selected bit line 16w to cause the memory cell to be written to a previous state. Also during read operations, column decode circuit 20 selects a memory cell string 12 and connects the memory cell string 12 via bit line 16r to detection circuit 26 using steering circuit 24.

[0025] The MRAM device 8 further includes a read circuit 22 for sensing the resistance of selected memory cells during read operations and a write circuit (not shown) for orienting the magnetization of selected memory cells during write operations.

[0026] The read circuit 22 includes a plurality of steering circuits 24 and sense amplifiers 26. Multiple bit lines 16r are connected to each steering circuit 24. Each steering circuit 24 includes a set of switches that connect a selected bit line 16r and a selected memory cell string 12 to a sense amplifier 26. An output of the sense amplifier 26 is supplied to a data register 30, which, in turn, is coupled to an I/O pad 32 of the MRAM device 8. If the MRAM device 8 has multiple levels of memory cell arrays (see, for example, Figure 7), bit lines 16r and memory cell strings 12 from the additional levels may be multiplexed into the sense amplifiers 26.

[0027] Control circuit 34 provides control signals such as timing signals to row decode circuit 18, column decode circuit 20, and read circuit 22.

[0028] Figure 3 illustrates an embodiment of a system 60 for reading a memory cell 70 in a memory cell string 12. System 60 includes one embodiment of memory cell string 12 and one embodiment of sense amplifier 26. Memory cell

string 12 is coupled to a transistor 72, transistor 72 is coupled to bit line 16r and steering circuit 24, and steering circuit 24 is coupled to bit line 16r and sense amplifier 26.

[0029] Memory cell string 12 includes memory cells 70a, 70b, 70c, and 70d, represented by resistors, coupled in series. Word lines 14a, 14b, 14c, and 14d are used to write memory cells 70a, 70b, 70c, and 70d, respectively, in conjunction with bit line 16w. A voltage source, V_{CC} , is coupled to one end of memory cell string 12 and the other end of memory cell string 12 is coupled to a ground source. The value of V_{CC} may be set to be equal to the sense voltage times the number of memory cells 70 in memory cell string 12. If the sense voltage is 0.5, for example, then V_{CC} for the embodiment of Figure 3 may be set to 0.5V times 4 or 2.0V. The V_{CC} of unselected memory cell strings 12 is set at the ground potential. The voltage source provides a voltage across memory cell string 12 in response to control signals received from row decode circuit 18, column decode circuit 20, and / or control circuit 34. In particular, the voltage source provides a voltage to the memory cell string 12 in response to a read operation to allow one or more of memory cells 70a, 70b, 70c, and 70d to be read.

[0030] In the embodiment of Figure 3, the gate connection of transistor 72 is coupled to the node between memory cells 70b and 70c, the drain connection of transistor 72 is coupled to a voltage source, V_{DD} , and the source connection of transistor 72 is coupled to bit line 16r. Memory cells 70a, 70b, 70c, and 70d form a voltage divider and node V_G forms a voltage tap in memory cell string 12. Transistor 72 is operated as a source follower to reflect the voltage present at the gate connection, V_G , to the source connection in response to the voltage, V_{CC} , being applied to memory cell string 12. Accordingly, transistor 72 causes the voltage present at the node between memory cells 70b and 70c to be reflected on bit line 16r.

[0031] Each memory cell string 12 in array 10 is coupled to a transistor 72 which is coupled to a bit line 16r. Each transistor 72 may be physically located near the memory cell string 12 to which it is coupled. By applying a voltage, V_{CC} , to a selected memory cell string 12 coupled to a bit line 16r, row decode

circuit 18 causes the voltage, V_G , from the selected memory cell string 12 to be reflected onto the bit line 16r as will be described in additional detail below. A voltage, V_{CC} , is not applied to the other memory cell strings 12 coupled to the bit line 16r during the time the voltage, V_G , from the selected memory cell string 12 is reflected onto the bit line 16r.

[0032] Each steering circuit 24 is coupled to from 4 to 256 bit lines 16r.

According, steering circuit 24 is coupled to the source connection of transistor 72 for each bit line 16r. Steering circuit 24 provides the voltage from a selected bitline 16r, which in turn is coupled to memory cell string 12 via voltage follower transistor 72, to sense amplifier 26.

[0033] Sense amplifier 26 is coupled to bit line 16r, a node between memory cells 70b and 70c through transistor 72 and steering circuit 24. Sense amplifier 26 includes a switch circuit 74, a capacitor 76, a differential amplifier 78, and a signal amplifier 80.

[0034] Switch circuit 74 is configured to selectively couple bit line 16r to one of the inputs of differential amplifier 78 in response to a control signal. The control signal causes switch circuit 74 to couple bit line 16r to the positive input of differential amplifier 78 to transmit a first voltage, V_1 , at a first time. Capacitor 76 stores the first voltage for a limited time. At a second time, the control signal causes switch circuit 74 to couple bit line 16r to the negative input of differential amplifier 78 to transmit a second voltage, V_2 .

[0035] In response to the first and second voltages, differential amplifier 78 generates a differential output voltage, V_{DIFF} , which is provided to signal amplifier 80. Signal amplifier 80 amplifies the differential output voltage to a logic output voltage, V_{OUT} , that can be stored as a logic level, i.e., a '0' or a '1'.

[0036] Figure 4 is a flow chart illustrating an embodiment of a method for reading a memory cell in the embodiment of memory cell string 12 shown in Figure 3. In Figure 4, a voltage, V_{CC} , is provided to memory cell string 12 as indicated in a block 402. A first voltage is detected at a node in memory cell string 12 as indicated in a block 404. In particular, transistor 72 and switching circuit 74 cause the voltage present at the node V_G between memory cells 70b

and 70c at a first point in time to be detected and stored on capacitor 76 as described above.

[0037] A selected memory cell in memory cell string 12, e.g., memory cell 70b, is written to a first state as indicated in a block 406. In one embodiment, the first state may be anti-parallel to represent a logic level of '1'. In other embodiments, the first state may be parallel to represent a logic level of '0'.

[0038] A second voltage is detected at a node in memory cell string 12 as indicated in a block 408. In particular, transistor 72 and switching circuit 74 cause the voltage present at the node V_G between memory cells 70b and 70c at a second point in time to be detected and provided to the negative input of differential amplifier 78. The second voltage is detected subsequent to the selected memory cell, e.g., memory cell 70b, being written to the first state.

[0039] A determination is made by sense amplifier 26 as to whether the first voltage differs from the second voltage as indicated in a block 410. The determination is made using differential amplifier 78 and signal amplifier 80. If the first voltage does not differ from the second voltage, then a first logic level associated with the first state is read out from the selected memory cell, e.g., memory cell 70b, as indicated in a block 412. If the first voltage differs from the second voltage, then a second logic level associated with the second state is read out from the selected memory cell, e.g., memory cell 70b, as indicated in a block 414. In addition, the selected memory cell, e.g., memory cell 70b, is written to the second state as indicated in a block 416.

[0040] Sense amplifier 26 causes the first or second logic level to be read out from the selected memory cell by causing a '1' or a '0' to be stored in register 30 and to be provided to I/O pad 32.

[0041] As noted above, the parallel state and the anti-parallel state cause different resistances to be measured across a memory cell. By applying a voltage across memory cell string 12, a voltage can be detected at a node between memory cells in the string prior to and subsequent to a selected memory cell being written to a known state. If the known state matches the previous state of the selected memory cell, then the resistance of the cell will not change and the voltage detected at the node subsequent to the write will be roughly the same

as the voltage detected at the node prior to the write. If the known state does not match the previous state of the selected memory cell, then the resistance of the cell will change and the voltage detected at the node subsequent to the write will differ from the voltage detected at the node prior to the write. In this way, memory cell string 12 effectively functions as a voltage divider circuit.

[0042] If the write in block 406 caused the state of the selected memory cell to change, then the memory cell is re-written to its original state as illustrated by block 416. If the write in block 406 did not cause the state of the selected memory cell to change, then the memory cell remains in its original state and may not need to be re-written.

[0043] Control circuit 34 provides appropriate timing signals to row decode circuit 18, write decode circuit 20, read circuit 22, steering circuit 24 and sense amplifier 26 to allow the functions of the method shown in Figure 4 to be performed.

[0044] Any one of the memory cells 70a, 70b, 70c, and 70d may be read using the method just described. Although four memory cells are shown in the memory cell string illustrated in Figure 3, other memory cell strings may include other numbers of memory cells coupled in series.

[0045] Although the gate connection of transistor 72 is coupled to the node between memory cells 70b and 70c in the embodiment shown in Figure 3, the gate connection may be coupled to a node between other memory cells, such as the node between memory cells 70a and 70b or the node between memory cells 70c and 70d, in other embodiments.

[0046] In addition, the source connection of transistor 72 may be coupled to the node between memory cells 70b and 70c, the gate connection of transistor 72 may be coupled to a voltage source and the drain connection of transistor 72 may be coupled to bit line 16 in other embodiments. Alternatively in other embodiments, the drain connection of transistor 72 may be coupled to the node between memory cells 70b and 70c, the gate connection of transistor 72 may be coupled to a voltage source and the source connection of transistor 72 may be coupled to bit line 16 in other embodiments.

[0047] Transistor 72 comprises a voltage follower transistor. In other embodiments, transistor 72 may be a bi-polar transistor and may be configured as an emitter follower in one or more of these embodiments.

[0048] Figure 5 illustrates an embodiment of a system 90 for reading a memory cell 70 in a memory cell string 12. System 90 includes one embodiment of memory cell string 12, one embodiment of sense amplifier 26, and one embodiment of register 30. Memory cell string 12 is coupled to a transistor 92, transistor 92 is coupled to bit line 16r and steering circuit 24, and steering circuit 24 is coupled to bit line 16r and sense amplifier 26.

[0049] Memory cell string 12 includes memory cells 70a, 70b, 70c, and 70d, represented by resistors, coupled in series. Word lines 14a, 14b, 14c, and 14d are used to write memory cells 70a, 70b, 70c, and 70d, respectively, in conjunction with bit line 16w.

[0050] A voltage source, V_A or V_B , may be selectively coupled to either end of memory cell string 12 with a ground source coupled to the opposite end of the coupled voltage source. Both ends of unselected memory cell strings 12 are coupled to ground sources. The voltage source V_A or V_B is selected with reference to the memory cell to be read. In particular, V_A is coupled to memory cell string 12 and a ground source is coupled to the other end of memory cell string 12 to read memory cell 70a or 70b. Similarly, V_B is coupled to memory cell string 12 and a ground source is coupled to the other end of memory cell string 12 to read memory cell 70c or 70d. The voltage sources V_A and V_B provide a voltage across memory cell string 12 in response to control signals received from row decode circuit 18, column decode circuit 20, and / or control circuit 34. In one embodiment, column decode circuit 20 causes V_A or V_B to be provided to memory cell string 12 to select string 12 and allow a read operation to be performed on a memory cell 70 in string 12.

[0051] In the embodiment of Figure 5, the gate connection of transistor 92 is coupled to the node between memory cells 70b and 70c, the drain connection of transistor 92 is coupled to a voltage source, V_{DD} , and the source connection of transistor 92 is coupled to bit line 16r. The node V_G forms a voltage tap in memory cell string 12. Transistor 92 is operated as a source follower to reflect

the voltage present at the gate connection, V_G , to the source connection in response to the voltage, V_{DD} , being applied to the drain connection.

Accordingly, transistor 92 causes the voltage present at the node V_G between memory cells 70b and 70c to be reflected on bit line 16r.

[0052] Each memory cell string 12 in array 10 is coupled to a transistor 92 which is coupled to a bit line 16r. Each transistor 92 may be physically located near the memory cell string 12 to which it is coupled. By applying a voltage, V_A or V_B , to a selected memory cell string 12 coupled to a bit line 16r, row decode circuit 18 causes the voltage, V_G , from the selected memory cell string 12 to be reflected onto the bit line 16r as will be described in additional detail below. A voltage, V_A or V_B , is not applied to the other memory cell strings 12 coupled to the bit line 16r during the time the voltage, V_G , from the selected memory cell string 12 is reflected onto the bit line 16r.

[0053] Each steering circuit 24 is coupled to from 4 to 256 bit lines 16r.

According, steering circuit 24 is coupled to the source connection of transistor 92 for each bit line 16r. Steering circuit 24 provides the voltage from a selected bitline 16r, which in turn is coupled to memory cell string 12 via voltage follower transistor 92, to sense amplifier 26.

[0054] Sense amplifier 26 is coupled to bit line 16r and a node between memory cells 70b and 70c through transistor 92 and steering circuit 24. Sense amplifier 26 comprises a clocked, two stage, self-referencing amplifier and includes a transistor 92, a current source 96, a differential amplifier 100, a switch 102, a capacitor 104, and a differential amplifier 106.

[0055] Capacitor 108 represents the load on bit line 16r caused by other memory cell strings 12 coupled to bit line 16r. Current source 96 is operable to discharge or act as the load on bit line 16r to increase the speed of the circuit. In other embodiments, current source 96 may be replaced by a resistor.

[0056] Bit line 16r is coupled through steering circuit 24 to the positive input of differential amplifier 100. Differential amplifier 100 comprises the first stage of sense amplifier 26. The first state causes sense amplifier 26 to be self-referenced by compensating for voltage, temperature, memory cell resistance, and system variations.

[0057] The output of differential amplifier 100 is coupled to switch 102. Switch 102 is configured to couple the output of differential amplifier 100 to capacitor 104, the negative input of differential amplifier 100, and the positive input of differential amplifier 106 in response to being closed. When closed, switch 102 effectively causes a first voltage, V_1 , from bit line 16r to be stored across capacitor 104 at a first time. In response to being opened, switch 102 causes the output of differential amplifier 100 to be coupled only to the negative input of differential amplifier 106. As a result, a second voltage from bit line 16r, V_2 , is coupled to the input of differential amplifier 106 at a second time.

[0058] Current source 96, differential amplifier 100, switch 102, and capacitor 104 operate as a charge-balanced sample and hold circuit to set a reference voltage for both stages of sense amplifier 26.

[0059] Differential amplifier 106 comprises the second stage of sense amplifier 26. Differential amplifier 106 compares the first and second voltages and produces a differential output voltage, V_{OUT} .

[0060] The differential output voltage is provided to sense latch 110. Sense latch 110 is reset to a high impedance state using the reset 'R' input prior to receiving the output from differential amplifier 106. In response to the data transfer signal, D_{XFER} , the differential output voltage is stored in a sense latch 110 as a logic level, i.e., a '0' or a '1'. Sense latch 110 amplifies the output signal, D_{OUT} , to a full scale output signal. Sense latch 110 is part of register 30.

[0061] Figure 6 is a flow chart illustrating an embodiment of a method for reading a selected memory cell in the embodiment of memory cell string 12 shown in Figure 5. In Figure 6, a voltage source is provided to an end of a memory cell string 12 closest or nearest to the selected memory cell in the memory cell string as indicated in a block 602. A ground source is provided to the other end of memory cell string 12 as indicated in a block 604.

[0062] The voltage source and ground source are coupled to cause the selected memory cell to be closest to the supply voltage (V_A or V_B) of the voltage divider circuit formed by the voltage source, the ground source, and memory cells 70a, 70b, 70c, and 70d. Accordingly, the end of memory cell string 12 that is closest or nearest to a selected memory cell 70 is the end that would put the selected

memory cell between voltage source V_A or V_B and the voltage divider tap node V_G . This closest end is coupled to a voltage source V_A or V_B and the end opposite the closest end is coupled to a ground source. The supply voltage V_A or V_B may be coupled to V_{DD} .

[0063] For example, if memory cell 70a or 70b is selected to be read, then the voltage V_A is applied across memory cell string 12 and the end of memory cell string 12 indicated by V_B is coupled to a ground source. If memory cell 70c or 70d is selected to be read, then the voltage V_B is applied as indicated in Figure 5 and the end of memory cell string 12 indicated by V_A is coupled to a ground source.

[0064] By switching the voltage and ground sources based on the relative position of the selected memory cell in the memory cell string as just described, the signals provided to sense amplifier 26 may be at a desired polarity to allow the design of sense amplifier 26 to be simplified.

[0065] A first voltage detected at a node in memory cell string 12 is stored as indicated in a block 606. In particular, transistor 92, differential amplifier 100, and switch 102 cause the voltage present at the node V_G between memory cells 70b and 70c at a first point in time to be detected and stored on capacitor 104 as described above. A voltage, V_A or V_B , is applied to memory cell string 12 to develop a voltage divider voltage to be applied at the gate of transistor 92 to cause a sense voltage to be transmitted to the input of differential amplifier 100. The voltage, V_A or V_B , may be equal to V_{DD} .

[0066] The selected memory cell in memory cell string 12, e.g., memory cell 70b, is written to a first state as indicated in a block 608. In one embodiment, the first state may be anti-parallel to represent a logic level of '1'. In other embodiments, the first state may be parallel to represent a logic level of '0'.

[0067] A second voltage is detected at a node in memory cell string 12 as indicated in a block 610. In particular, transistor 92, differential amplifier 100, and switch 102 cause the voltage present at the node V_G between memory cells 70b and 70c at a second point in time to be detected and provided to the negative input of differential amplifier 106. The second voltage is detected subsequent to the selected memory cell, e.g., memory cell 70b, being written to the first state.

[0068] A determination is made by differential amplifier 106 as to whether the first voltage differs from the second voltage as indicated in a block 612. If the first voltage does not differ from the second voltage, then a first logic level associated with the first state is read out from the selected memory cell, e.g., memory cell 70b, as indicated in a block 614. If the first voltage differs from the second voltage, then a second logic level associated with the second state is read out from the selected memory cell, e.g., memory cell 70b, as indicated in a block 616. In addition, the selected memory cell, e.g., memory cell 70b, is written to the second state as indicated in a block 618.

[0069] Sense amplifier 26 causes the first or second logic level to be read out from the selected memory cell by causing a '1' or a '0' to be stored in sense latch 110 in register 30 and to be provided to I/O pad 32.

[0070] Memory cell string 12 effectively functions as a voltage divider circuit in the embodiment of Figure 5.

[0071] If the write in block 608 caused the state of the selected memory cell to change, then the memory cell is re-written to its original state as illustrated by block 618. If the write in block 608 did not cause the state of the selected memory cell to change, then the memory cell remains in its original state and may not need to be re-written.

[0072] Control circuit 34 provides appropriate timing signals to row decode circuit 18, write decode circuit 20, read circuit 22, steering circuit 24 and sense amplifier 26 to allow the functions of the method shown in Figure 6 to be performed.

[0073] Any one of the memory cells 70a, 70b, 70c, and 70d may be read using the method just described. Although four memory cells are shown in the memory cell string illustrated in Figure 5, other memory cell strings may include other numbers of memory cells coupled in series.

[0074] Although the gate connection of transistor 92 is coupled to the node between memory cells 70b and 70c in the embodiment shown in Figure 5, the gate connection may be coupled to a node between other memory cells, such as the node between memory cells 70a and 70b or the node between memory cells 70c and 70d, in other embodiments.

[0075] Transistor 92 comprises a voltage follower transistor. In other embodiments, transistor 92 may be a bi-polar transistor in other embodiments and may be configured as an emitter follower in one or more of these embodiments.

[0076] In certain embodiments of memory cell string 12 described herein, the number of memory elements in a memory cell string 12 is equal to the preselected amount of sense voltage to be set across a single memory cell divided into the supply voltage (V_{CC} , V_A , or V_B) taken in groups of two. For example, if the sense voltage to be set is 0.5V and the supply voltage is 2.0V, then the preferred number of resistors in the string is 4. However, if the sense voltage to be set is 0.2V and V_{DD} is 2.0V, then the preferred number of resistors is 10.

[0077] A feature of memory cell string 12 is that the tap voltage V_G is close to the supply voltage (V_{CC} , V_A , or V_B) divided by 2, regardless of the nominal resistance of the memory cells. If, for example, $V_A = V_{DD} = 2.0V$, and there are 4 resistors in the string, V_G is about 1.0V, and if there are 10 resistors in the string, V_G is still about 1.0V.

[0078] The memory cell string supply voltage (V_{CC} , V_A , or V_B) is set large enough to activate the source follower transistors (i.e. transistors 72 or 92) to drive the bit lines 16 without significant signal loss. If the threshold voltage (V_{TH}) of a source follower transistor is 0.5V and a sense voltage of 0.5V is desired, $V_G = V_{TH} + V_{BL} = 0.5V + 0.5V = 1.0V$, and this will dictate a memory cell string supply voltage of 2.0V.

[0079] The relationship between the supply voltage, the voltage across a single memory cell, the number of memory cells in a memory cell string, and the signal sensed by the sense amplifier can be described in additional detail as follows. First, the MRAM resistance change ΔR is specified as the product of TMR (tunneling magnetoresistance ratio) and the nominal resistance of the MRAM memory cell, R . TMR is a strong function of the voltage applied across the memory cell V_{CELL} and is preferably in the range of 200mV to 500mV to yield TMR's of 10% to 35%.

[0080] Next, a string of N memory cells will nominally form a voltage divider with roughly an equal voltage drop across each memory cell: $V_{CELL} = V_{CC} / N$. Therefore, if V_{CC} is given to be 2.0V and V_{CELL} is selected to be 500mV, then $N=4$ as shown in embodiments of Figures 3 and 5. And if V_{CELL} is selected to be 200mV, then N would be 10.

[0081] Further, the sense amplifiers of Figure 3 and Figure 5 amplify the difference between the output of the voltage divider formed by the tapped node V_G when the selected memory cell is in state 1 (V_1) and in state 2 (V_2). The voltage difference is directly related to V_{CC} , N , and TMR as shown in the following equations (assuming state 1 is anti-parallel, state 2 is parallel, $N=4$ where the resistance of the memory cells are represented by R_1 , R_2 , R_3 , and R_4 , respectively, and R_1 is the selected memory cell):

$$[1] \quad V_1 = V_{CC} * (R_1 * (1+TMR) + R_2) / (R_1 * (1+TMR) + R_2 + R_3 + R_4)$$

$$[2] \quad V_1 \approx V_{CC} * (TMR/4 + 0.5)$$

$$[3] \quad V_2 = V_{CC} * (R_1 + R_2) / (R_1 + R_2 + R_3 + R_4)$$

$$[4] \quad V_2 \approx V_{CC} * 0.5$$

$$[5] \quad V_{DIFF} = V_1 - V_2$$

$$[6] \quad V_{DIFF} \approx V_{CC} * TMR/4$$

$$[7] \quad \text{Generally: } V_{DIFF} = V_{CC} * TMR / N$$

[0082] Accordingly, the voltage divider design selects V_{CC} , TMR, and N to provide sufficient signal to reliably amplify and sense. For the embodiment shown in Figure 3, $V_{DIFF} = 2.0V * 0.1/4 = 50mV$.

[0083] Reference is now made to Figure 7 which illustrates an embodiment of a multi-level MRAM chip 700. MRAM chip 700 includes a number Z of memory

cell levels or planes 702 that are stacked in a z-direction on a substrate 704. The number Z is a positive integer where $Z \geq 1$. Memory cell levels 702 may be separated by insulating material (not shown) such as silicon dioxide. Read and write circuits may be fabricated on substrate 704. The read and write circuits may include additional multiplexers for selecting the levels that are read from and written to.

[0084] Thus, disclosed is an MRAM device in which resistance states of memory cells can be sensed during read operations. The MRAM device described herein may be used in a variety of applications. Fig 8 shows an exemplary general application for one or more MRAM chips 700. The general application is embodied by a device 850 including a MRAM storage module 852, an interface module 854 and a processor 856. MRAM storage module 852 includes one or more MRAM chips 700 for non-volatile storage. Interface module 854 provides an interface between processor 856 and MRAM storage module 852. Device 850 could also include other types and / or levels of memory.

[0085] For a device 850 such as a notebook computer or personal computer, MRAM storage module 852 might include a number of MRAM chips 700 and interface module 854 might include an IDE or SCSI interface. For a device 850 such as a server, MRAM storage module 852 might include a greater number of MRAM chips 700, and interface module 854 might include a fiber channel or SCSI interface. Such MRAM storage modules 852 could replace or supplement conventional non-volatile storage devices such as hard drives.

[0086] For a device 850 such as a digital camera, MRAM storage module 852 might include a smaller number of MRAM chips 700 and interface module 854 might include a camera interface. Such a MRAM storage module 852 would allow non-volatile storage of digital images on-board the digital camera.

[0087] The above embodiments of the MRAM device may offer advantages over other MRAM devices. For example, the a higher level of memory cell densities may be achieved compared to other MRAM devices that include additional elements. Increased densities may result in decreased costs for a given amount of storage capacity. In addition, the memory cell strings described

herein may provide better electrical circuit isolation compared to previous MRAM devices. The improved isolation may allow for more reliable detection of the state of memory cells in a memory cell string.

[0088] The memory device is not limited to the specific embodiments described and illustrated above. For instance, an MRAM device is not limited to the use of spin dependent tunneling devices. Other types of devices that could be used include, but are not limited to, giant magnetoresistance (“GMR”) devices.

[0089] The MRAM device has been described in connection with the rows being oriented along the x-axis and columns being oriented along the y-axis.

However, the rows and columns could be transposed.

[0090] The memory device is not limited to MRAM cells. The memory device may include any type of memory cell in a resistive cross point array.